

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: M. OOE, et al.

Serial No.: 10/585,738

Filed: JULY 12, 2006

For: PHOTORESISTIVE POLYMER COMPOSITION, METHOD OF PRODUCING PATTERN AND ELECTRONIC PARTS

Art Unit: 1794

Examiner: Gerard T. Higgins
Conf. No.: 7230

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

February 17, 2009

SIR:

In response to the Office Action mailed October 15, 2008, please amend the above-identified application as listed in the following, and as set forth on the following pages:

AMENDMENTS TO THE CLAIMS; and

REMARKS are included following the amendments.